## CPC COOPERATIVE PATENT CLASSIFICATION

## C CHEMISTRY; METALLURGY

(NOTES omitted)

## **CHEMISTRY**

3/00

Ski waxes

C09 DYES; PAINTS; POLISHES; NATURAL RESINS; ADHESIVES; COMPOSITIONS NOT OTHERWISE PROVIDED FOR; APPLICATIONS OF MATERIALS NOT OTHERWISE PROVIDED FOR

## C09G POLISHING COMPOSITIONS (French polish C09F 11/00); SKI WAXES

1/00	Polishing compositions (French polish <u>C09F 11/00</u> ;
	detergents <u>C11D</u> )
1/02	• containing abrasives or grinding agents {(abrasives
	as such <u>C09K 3/14</u> ; polishing of semi-conductors
	<u>H01L</u> )}
1/04	• Aqueous dispersions ( <u>C09G 1/02</u> takes precedence)
1/06	<ul> <li>Other polishing compositions</li> </ul>
1/08	• • based on wax
1/10	based on mixtures of wax and natural or
	synthetic resin
1/12	mixtures of wax and silicon-containing
	polycondensates
1/14	<ul> <li>based on non-waxy substances</li> </ul>
1/16	• • on natural or synthetic resins
1/18	• • on other substances

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